Fabrication of some Quaternary Spinel Structure Electrodes for Photoelectrochemical Applications

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Abstract

In this study, nanostructured ZnNiCo\textsubscript{2}O\textsubscript{4} and MnNiCo\textsubscript{2}O\textsubscript{4} electrodes were fabricated by spray pyrolysis method and annealed at 550°C for 2 h. The structural, optical, and Photoelectrochemical properties were studied. The structural properties were examined using X-ray diffraction (XRD). The results show that the samples have a cubic spinel structure. The atomic percentage determined by (EDX) and the thickness (cross-section) of films measured by (FE-SEM), as well as the surface roughness measured through (AFM) are all used for analysis. The optical properties were investigated by UV-visible spectrophotometer, and the energy band gaps of ZnNiCo\textsubscript{2}O\textsubscript{4} and MnNiCo\textsubscript{2}O\textsubscript{4} were estimated to be approximately 2.2 and 2.4 eV respectively. The photoelectrochemical, comprising of photocurrent density, linear sweep voltammograms (LSV), and Mott-Schottky (MS), displayed flat band values of (1.5 eV and -0.55 eV) Vs NHE for ZnNiCo\textsubscript{2}O\textsubscript{4} and MnNiCo\textsubscript{2}O\textsubscript{4} respectively, where the conduction band and valance band values of ZnNiCo\textsubscript{2}O\textsubscript{4} were (C. B = -0.6 eV and V.B = 1.6 eV ), while those of MnNiCo\textsubscript{2}O\textsubscript{4} were (C.B= -0.65 eV and V.B= 1.75 eV ). The corresponding photocurrent densities for ZnNiCo\textsubscript{2}O\textsubscript{4} and MnNiCo\textsubscript{2}O\textsubscript{4} were 35 µA/cm\textsuperscript{2} and 50 µA/cm\textsuperscript{2}, respectively.
electrodes were comprehensively studied for ZnNiCo$_2$O$_4$ and MnNiCo$_2$O$_4$ under a neutral water condition.

**Keywords:** Photoelectrochemical, Transition Metal Oxides, Photocatalytic, Spinel Structure.

**Introduction**

The spinel structure of metal oxides has captivated the attention of materials scientists due to their exceptional physical and chemical features [1]. Investigating the decreased dimensionality...
of spinel-type metal oxides at the nanoscale has been conducted for a variety of applications, such as chemical gas sensors, High-capacity anode materials for Lithium-ion batteries, super-capacitors, pigments, catalysts, and spintronics [2]. The spinel structure has proven to be a particularly productive family of (MTMO) materials. Of particular interest is nickel cobaltite (NiCo$_2$O$_4$), which has been studied for its potential application in water electrolysis and oxygen evolution. The essential characteristics of spinel structures are highly contingent upon the precise distribution of cations occupying octahedral and tetrahedral sites in the cubic lattice of spinels. Despite their potential, these materials exhibit inadequate electrical conductivity. Different techniques like designing nano-architectures, compositing metal oxides with highly conductive polymers, and chemical substitution of Nobel metals were developed and demonstrated to drastically improve their electrochemical properties. Chemical substitution of metals in oxide nanostructures offers great promise for modulating electrochemical properties, as demonstrated by [3]. Mn-Ni-Co and Zn-Ni-Co oxides have also been identified as potential electrode materials due to their increased electrical conductivity and photoelectrochemical performance enhancement [4, 5]. In this study, we investigate the use of spinel cobaltites (ZnNiCo$_2$O$_4$, MnNiCo$_2$O$_4$) electrodes for photocatalytic applications, synthesized via the chemical spray pyrolysis (CSP) method.

**Experimental Procedure**

Nanostructured Cobaltite films (ZnNiCo$_2$O$_4$ and MnNiCo$_2$O$_4$) were deposited on a preheated FTO-coated glass substrate by using the spray pyrolysis method. The solutions are prepared using a mixture of Nickel nitrate (Ni(NO$_3$)$_2$.6H$_2$O), Cobalt nitrate (Co(NO$_3$)$_2$.6H$_2$O), Zinc nitrate (Zn(NO$_3$)$_2$.6H$_2$O) and Manganese acetate Mn(CH$_3$COO)$_2$.4H$_2$O, all of 0.05 M. All the salts were dissolved in 100 ml distilled water, and a final solution was prepared by combining (Zn:Ni:Co) and (Mn:Ni:Co) solutions at a volumetric ratio of (0.5:0.5:2), and stirring the mixture for 20 minutes using a magnetic stirrer, resulting in a clear and homogeneous solution. The FTO-coated glass substrates were cleaned ultrasonically with ethanol and DIW followed by being dried at 80°C for 30 min to eliminate the impurities remaining on the substrate. The spraying temperature was 400°C, and the time of spray was 10 sec, the distance between the
substrate to a nozzle was ±30cm, and the spray rate was 5 mL/min. The films were then annealed at a temperature of 550°C for 2 h, other parameters were detailed in Table 1. The deposited electrodes were characterized using X-ray diffraction (XRD) analysis with Cu-Kα radiation. The Atomic Force Microscope (AFM) was utilized to assess the roughness, root mean square, and average diameter of particles. The cross-section of the films and EDX were investigated using a Field emission scanning electron microscope (FE-SEM).

**Table 1:** Experimental parameters of spray pyrolysis deposition process.

<table>
<thead>
<tr>
<th>PARAMETER</th>
<th>VALUE</th>
</tr>
</thead>
<tbody>
<tr>
<td>Solution concentration</td>
<td>0.05 M</td>
</tr>
<tr>
<td>Volumetric ratio</td>
<td>0.5:0.5:2</td>
</tr>
<tr>
<td>Deposition temperature</td>
<td>400 °C</td>
</tr>
<tr>
<td>Annealing temperature</td>
<td>550 °C for 2 h</td>
</tr>
<tr>
<td>Distance between the substrate to a nozzle</td>
<td>30 cm</td>
</tr>
<tr>
<td>Spray rate</td>
<td>5 mL/min</td>
</tr>
<tr>
<td>Air pressure</td>
<td>1.5 bar</td>
</tr>
</tbody>
</table>

**Photoelectrochemical Characterization**

The cell of photocatalysis employs a three-electrode setup immersed in an aqueous electrolyte (Na₂SO₄), as depicted in Figure 1. This configuration consists of two active electrodes: a photoanode (Pt: Platinum wire) and a photocathode (film) as well as a third electrode (Ag/AgCl: Silver/silver chloride) serving as the reference electrode. The electrodes were immersed in an electrolyte solution of sodium sulfate Na₂SO₄ with a concentration of 0.5M. The tests were conducted at ambient temperature. The photo-current was measured by (DY2300 POTENTIOSTAT), at an applied potential of (-0.5 v). Linear sweep voltammetry (LSV) curves were recorded at a scan rate of 5 mV.s⁻¹.
Results and Discussion

Structure properties

Crystal structure
The spinel structures of Cobaltite films (ZnNiCo$_2$O$_4$, MnNiCo$_2$O$_4$) were presented in Figure 2, exhibiting the spinel crystal structure. The Tetrahedral (T$_d$) sites were occupied by Co ions while the Octahedral (O$_h$) sites were shared between (Ni and Zn or Mn) and Co. In the series ZnNi$_x$Co$_{2-x}$O$_4$ spinels, tetrahedral sites were occupied by the inactive Zn$^{2+}$ to rule out their catalytic contributions, and emphasize the catalytically more active octahedral sites. Ni was employed as a substitute for octahedrally coordinated Co to facilitate the adjustable modification of electronic structure [6].

Figure 1: Diagram of Photoelectrochemical Cell.
The XRD pattern of synthesized films is shown in Figure 3. The XRD analysis indicated that the polycrystalline films were a pure phase and all samples confirm the formation of cubic spinel structure of Cobaltites films. The diffracted peaks of the quaternary spinel Cobaltites (ZnNiCo$_2$O$_4$ and MnNiCo$_2$O$_4$) are positioned at 31.4°, 36.9°, 54.5°, 59.4°, and 65.5°. The values match well with a cubic spinel structure standard ICDD file no.#73-1701 [7]. The diffraction peaks of spinel samples correspond to the (hkl) indices (220), (311), (422), (511) and (440), respectively.
The average crystallite size of films is calculated using the Scherrer equation [8]:

\[ D = \frac{0.9\lambda}{\beta \cos \theta} \]  

\[ .......... \text{(1)} \]

where D: The average crystallite size, \( \lambda \): wavelength and \( \beta \): full width at half maximum.

The average crystallite sizes of ZnNiCo\(_2\)O\(_4\) and MnNiCo\(_2\)O\(_4\) films are approximately (19.3 and 16.8) nm, respectively. The lattice parameters are shown in Table 2. The lattice parameters of the cubic lattice are determined from d spacing for the plane of (3 1 1) at the 2\( \theta \) value of 36.9° and 36.7° of ZnNiCo\(_2\)O\(_4\) and MnNiCo\(_2\)O\(_4\) films respectively by using equation [9]:

\[ \frac{1}{d^2_{hkl}} = \frac{h^2+k^2+l^2}{a^2} \]  

\[ .......... \text{(2)} \]

where \( d \) is the interplanar spacing, and \( h, k, l \) are the Miller indices.

The results of the structure properties of Cobaltites films are in good agreement with the reported values of ZnNiCo\(_2\)O\(_4\) [7, 9 and 10] and MnNiCo\(_2\)O\(_4\) films [11].

**Table 2:** Crystallite sizes and lattice parameters of films.

<table>
<thead>
<tr>
<th>SAMPLE</th>
<th>2( \theta )</th>
<th>FWHM</th>
<th>( D_{\text{avg}} ) (NM)</th>
<th>( D_{311} ) (Å)</th>
<th>LATTICE CONSTANTS ( A=B=C ) (Å)</th>
<th>THE VOLUME OF UNITE CELL (NM(^3))</th>
</tr>
</thead>
<tbody>
<tr>
<td>ZnNiCo(_2)O(_4)</td>
<td>36.9</td>
<td>0.434</td>
<td>19.3</td>
<td>0.2437</td>
<td>0.808</td>
<td>0.5281</td>
</tr>
<tr>
<td>MnNiCo(_2)O(_4)</td>
<td>36.7</td>
<td>0.496</td>
<td>16.8</td>
<td>0.2423</td>
<td>0.803</td>
<td>0.519</td>
</tr>
</tbody>
</table>

**FE-SEM measurements**

The cross-section of Cobaltite films deposited at 400°C, and annealed at 550°C, was characterized by FE-SEM. As shown in Figures 4, the FE-SEM images indicate good grains growth. Variations in the grain size of NiCo\(_2\)O\(_4\) are not only influenced by the preparation parameters, such as heat treatment, but also by the number of substituents (Zn, Mn) present in the parent matrix [12]. The EDX images of ZnNiCo\(_2\)O\(_4\) and MnNiCo\(_2\)O\(_4\) films are presented in Figure 5, and their atomic percentages are reported in Table 3.
Figure 4: FE-SEM (Cross Section) of ZnNiCo$_2$O$_4$ and MnNiCo$_2$O$_4$ films.

Table 3: EDX atomic percent of ZnNiCo$_2$O$_4$ and MnNiCo$_2$O$_4$ films.

<table>
<thead>
<tr>
<th>SAMPLE</th>
<th>O %</th>
<th>CO %</th>
<th>NI %</th>
<th>ZN %</th>
<th>MN %</th>
</tr>
</thead>
<tbody>
<tr>
<td>ZnNiCo$_2$O$_4$</td>
<td>50.55</td>
<td>32.22</td>
<td>7.54</td>
<td>9.69</td>
<td></td>
</tr>
<tr>
<td>MnNiCo$_2$O$_4$</td>
<td>60.86</td>
<td>27.53</td>
<td>6.75</td>
<td>4.86</td>
<td></td>
</tr>
</tbody>
</table>

Figure 5: EDX images of ZnNiCo$_2$O$_4$ and MnNiCo$_2$O$_4$ films.

AFM measurements

The morphology of ZnNiCo$_2$O$_4$ and MnNiCo$_2$O$_4$ films was studied by atomic force microscopy (AFM). Figure 6 displays images of the surfaces depicting a uniform and homogenous growth.
on the substrate. Table 4 presents the average diameter, root mean square, and roughness average of Cobaltite films.

**Table 4:** AFM results of ZnNiCo$_2$O$_4$ and MnNiCo$_2$O$_4$ films.

<table>
<thead>
<tr>
<th>SAMPLE</th>
<th>ROUGHNESS AVERAGE (NM)</th>
<th>RMS (NM)</th>
<th>AVERAGE DIAMETER (NM)</th>
</tr>
</thead>
<tbody>
<tr>
<td>ZnNiCo$_2$O$_4$</td>
<td>4</td>
<td>5.13</td>
<td>68.95</td>
</tr>
<tr>
<td>MnNiCo$_2$O$_4$</td>
<td>3.83</td>
<td>4.9</td>
<td>146.09</td>
</tr>
</tbody>
</table>

**Figure 6:** AFM images of: a) ZnNiCo$_2$O$_4$ b) MnNiCo$_2$O$_4$
Optical measurements

UV–visible absorption spectra of ZnNiCo$_2$O$_4$ and MnNiCo$_2$O$_4$ films in the wavelength range of 350–1000 nm were shown in Figure 7. The absorbance spectrum reveals that the films have considerable absorption across the entire visible range (350–1000 nm), indicating a strong absorption of most of the visible wavelengths. When compared to a solar spectrum, which has a notable intensity in the visible range, it suggests that these films are viable materials to be used as solar absorbers [13].

The energy band gap was determined by plotting $(\alpha.E)^2$ against the photon energy (E) of the films, as shown in Figure 7. The absorption edges of quaternary films in the Tauc plot cuts the abscissa at 2.2 eV and 2.4 eV for ZnNiCo$_2$O$_4$ and MnNiCo$_2$O$_4$ films respectively, which agrees well with the reported values of Cobaltites films [14], [15], [16]. The band-gap energy is determined using the equation [17].

$$\alpha h \nu = B_o (h \nu - E_{g, opt})^r$$

The band gap results in the films, allowing them to absorb all visible wavelengths in the range of visible region (400-1000 nm).

**Figure 7:** UV–Vis Absorbance spectrums and Energy gaps of ZnNiCo$_2$O$_4$ and MnNiCo$_2$O$_4$ films.
Characterization of Photocatalytic Activity

Linear sweep voltammetry (LSV)

The Photoelectrochemical (PEC) activity of Cobaltites electrodes was studied by using Photoelectrochemical cell, featuring a standard photoanode (Platinum wire as a counter electrode) and Ag/AgCl (Silver/Silver chloride) as reference electrode, whilst ZnNiCo$_2$O$_4$ and MnNiCo$_2$O$_4$ electrodes acted as the photocathodes. The results of current density were measured at a scan rate of 5 mV.s$^{-1}$ in Na$_2$SO$_4$ electrolyte with a concentration of 0.5 M. The light source was a 60-watt halogen lamp. Figure 8 presents the LSV of ZnNiCo$_2$O$_4$ and MnNiCo$_2$O$_4$ electrodes. At (-0.5 V), the films produced the highest photocurrent of 30 and 39 $\mu$A/cm$^2$ for ZnNiCo$_2$O$_4$ and MnNiCo$_2$O$_4$ respectively, indicating photocatalyst activity under illumination. The $I$–$V$ curve displays a nonlinear behavior, which may be attributed to the Schottky barrier at the metal–semiconductor contacts [14].

Photoelectrochemical cells were used to analyze the photocurrent density stability of ZnNiCo$_2$O$_4$ and MnNiCo$_2$O$_4$ electrodes by switching off and on the light every 60 seconds. Figure 9 shows photocurrent density curves of nanostructured electrodes, which exhibit PEC activity with the photocurrent densities of (35 and 50) $\mu$A/cm$^2$ at -0.5 V for ZnNiCo$_2$O$_4$ and MnNiCo$_2$O$_4$ respectively.

![Figure 8: Linear Sweep Voltammograms (LSV) of ZnNiCo$_2$O$_4$ and MnNiCo$_2$O$_4$ Electrodes.](image-url)
Figure 9: Photocurrent densities of ZnNiCo$_2$O$_4$ and MnNiCo$_2$O$_4$ Electrodes.

Band structure

The flat band potential ($E_{fb}$) is a crucial parameter for assessing the performance of photoelectrodes, and can be used to estimate the positions of band edges in new materials [18]. The flat band potential is a fundamental factor that gives information that allows the estimation of the conduction band edge potential at the surface of the semiconductor [19]. The flat-band potential values were determined from the Mott-Schottky plot presented in Figure 10. The flat-band potentials of electrodes were calculated from the x-intercept of the linear region. The curves illustrated that the behaviors of the electrodes are p-type (negative slope) and n-type (positive slope) with flat band values of (1.5 V and -0.55 V) vs. NHE for ZnNiCo$_2$O$_4$ and MnNiCo$_2$O$_4$ respectively. The conduction band and valance band values of ZnNiCo$_2$O$_4$ and MnNiCo$_2$O$_4$ electrodes were found to be (C.B= -0.6 eV and V.B= 1.6 eV ) and (C.B= -0.65 eV and V.B= 1.75 eV ) respectively. The general relation between electrode capacitance (C) and applied voltage value (E) for n-type and p-type semiconductors is described by the following form of the Mott-Schottky equation (4) [19]:

$$\frac{1}{C^2} = \frac{2}{\varepsilon \varepsilon_0 A^2 q N q} \left( -E + E_{FB} + \frac{KBT}{q} \right) \quad \text{…………(4)}$$
This study is the first to systematically investigate the photocatalytic properties of ZnNiCo$_2$O$_4$ and MnNiCo$_2$O$_4$ Cobaltite electrodes using photocurrent, LSV, and flat band potential determination techniques in photoelectrochemical systems.

**Conclusion**

Nanostructured cobaltite electrodes were deposited onto FTO-coated glass substrates via spray pyrolysis, followed by annealing at 550°C for two hours. The structural study revealed that the electrodes have a spinel structure. The nanocrystalline grain surface morphology was observed from (AFM), and the atomic percent was calculated by field emission scanning electron micrograph images (FE-SEM). UV–vis absorption spectra of glass samples exhibited that the films had a good absorption with a band gap of (2.2 and 2.4 eV) for ZnNiCo$_2$O$_4$ and MnNiCo$_2$O$_4$ respectively. The electrodes exhibited good PEC activity in terms of photocurrent density at a scan rate 5 mV/s, while Mott-Schottky measurements revealed p-type and n-type behavior of the flat-band potential. The conduction band and valance band values for ZnNiCo$_2$O$_4$ were (C. B= -0.6 eV and V.B= 1.6 eV ), while those of MnNiCo$_2$O$_4$ were (C.B= -0.65 eV and V.B= 1.75 eV ). These findings make Cobaltite electrodes suitable for the fabrication of heterojunctions for photocatalytic applications.
References


